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Application Number		10799349				
Filing Date		2004-03-12				
First Named Inventor	David	Hoerl				
Art Unit		2629				
Examiner Name	Jeffre	y J. Piziali				
Attorney Docket Num	hor	105479.58428				

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	1	Trial Transcript, Apex v. Rainfan, Southern District of New York, Case No.: 01-CV-4435, Volume 7, January 2002.	
	2	Tron International, Inc., KVM Products Catalogs, 1997.	
	3	Tron International, Inc., Products Catalogs, 1996.	
	4	Tron International, Inc., Product Brochure, 1897, 4 pages.	
	5	Unisys, PW2 Advantage Series Rackmount Server, 1995.	
	6	Yee Law Deposition Transcript, Case No.: 01-CV-4435, March 3, 2005.	
	7	Yee-Shung Liaw Deposition Transcript, Case No.: 01-CV-4435, December 6, 2001.	
	8	The list of docket reports in the lifigation: Avocent Redmond Corp. v. Rantian Computer, Inc., Civil Action No. 1:01- CV-04435(PKC), United States District Court for the Southern District of New York	
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